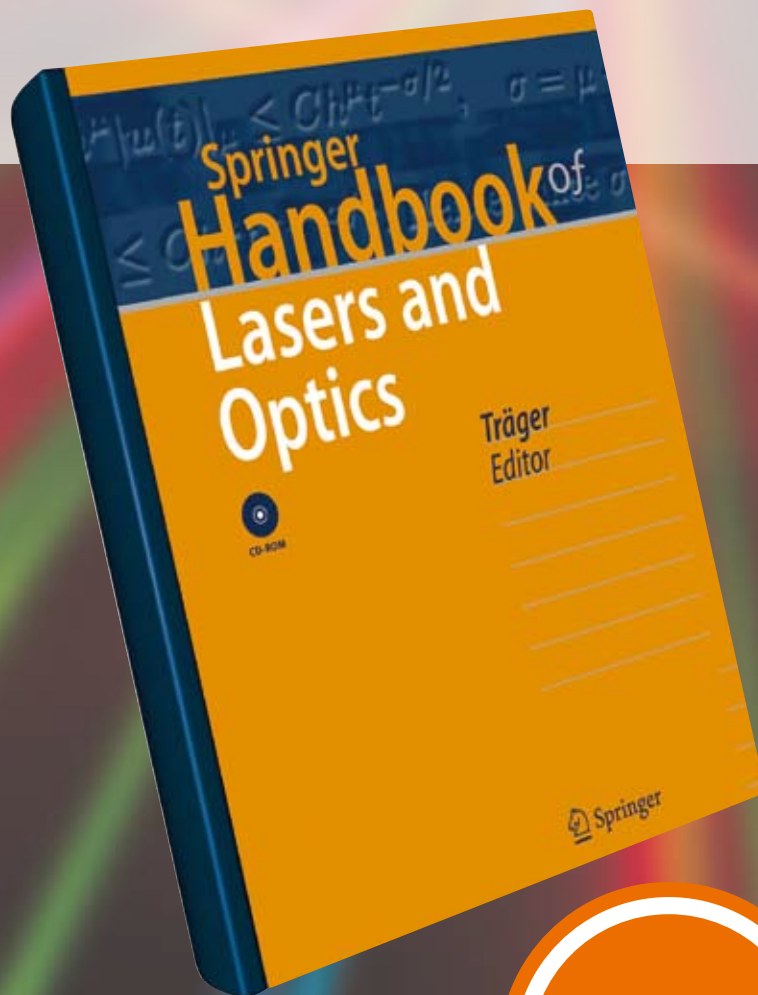
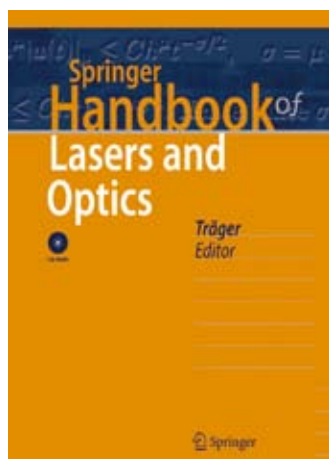


Springer Handbook of Lasers and Optics

F. Träger, Editor. Foreword by T. W. Hänsch

- Includes latest research and applications





Springer Handbook of Lasers and Optics

Comprehensive, up-to-date, and easy-to-use, the Springer Handbook of Lasers and Optics provides you with expert rundowns of the latest developments in this applied and rapidly developing field in a lab-friendly format.

Written by acknowledged experts from around the world (including a foreword by 2006 Nobel Laureate T. W. Hänsch), each chapter provides descriptive text, graphics, illustrations, charts, and references for easy use in the laboratory or

the office. The included disc contains the text of the Handbook, making it easy to consult while writing or performing desk research.

Organized into four parts, the Handbook's 22 chapters cover basic principles and materials, fabrication and properties of optical components, coherent and incoherent light sources, as well as selected applications and special fields such as terahertz photonics, X-ray optics, and holography.

Sample chapter available at springer.com!

Key features:

- ▶ Contains over 980 two-color illustrations
- ▶ Includes over 120 comprehensive tables with properties of optical devices and materials
- ▶ Contains an Abbe Diagram including data of all glass manufacturers
- ▶ Emphasizes physical concepts over extensive mathematical derivations
- ▶ Parts and chapters with summaries, detailed index and fully searchable CD-ROM guarantee quick access to data and links to other sources
- ▶ Delivers a wealth of up-to-date references

Key topics:

- ▶ Basic Optics Principles
- ▶ Coherent and Incoherent Light Sources
- ▶ Ultrafast Physics and Spectroscopies
- ▶ Optical Materials and Their Properties
- ▶ Fabrication and Properties of Optical Components
- ▶ Selected Applications and Special Fields: Nanooptics, Quantum Optics, X-Ray Optics, Terahertz Photonics and Holography

Springer Handbook of Lasers and Optics Träger, Frank (Ed.) 2007, Approx. 1310 p., 500 illus., 500 in color, with CD-ROM, Hardcover
ISBN 978-0-387-95579-7 ▶ **\$199.00**

Contributors

Andreas Assion, Femtolasers Produktions GmbH

Thomas Bauer, Coating Department, JENOPTIK Polymer Systems GmbH

Thomas Baumert, Institut für Physik, Universität Kassel

Dietrich Bertram, Philips Lighting

Klaus Bonrad, Division Luminescence Technology, Schott Spezialglas AG

Matthias Born, Philips Research Laboratories Aachen

Annette Borsutzky, Fachbereich Physik, Universität Kaiserslautern

Hans H. Brand, Department of Electrical, Electronic and Communication Engineering, Friedrich-Alexander-University of Erlangen-Nürnberg/LHFT

Robert P. Bréault, Breault Research Organization, Inc.

Matthias Brinkmann, Mathematics and Natural Sciences, University of Applied Sciences Darmstadt

Uwe Brinkmann, freelancer

Robert Brunner, Central Research and Technology, Carl Zeiss AG

Prof. Geoffrey W. Burr, IBM Almaden Research Center,

Karsten Buse, Institute of Physics, University of Bonn

Carol Click, Regional Research and Development, Schott North America

Prof. Hans Coufal, deceased

Mark Davis, Regional Research and Development, Schott North America

Giuseppe Della Valle, Department: Department of Physics, Polytechnic Institute of Milan

Wolfgang Demtröder, Department of Physics, TU Kaiserslautern

Henrik Ehlers, Laser Zentrum Hannover e.V.

Rainer Engelbrecht, Department of Electrical, Electronic and Communication Engineering

Friedrich-Alexander-University of Erlangen-Nürnberg

Martin Fally, Faculty of Physics, Department for Experimental Physics, University of Vienna

Yun-Hsing Fan, College of Optics and Photonics, University of Central Florida

Enrico Geißler, Central Research and Technology, Carl Zeiss AG

Ajoy Ghatak, Physics Department, Indian Institute of Technology Delhi

Olesandr Goushcha, SEMICOA

Daniel Grischkowsky, Electrical and Computer Engineering, Oklahoma State University

Richard Haglund, Department of Physics and Astronomy, Vanderbilt University

Stefan Hansmann, AI Technologies GmbH

Joe Hayden, Regional Research and Development, Schott North America

Joachim Hein, Institute for Optics and Quantum Electronics, Friedrich-Schiller University Jena

Stefan W. Hell, Max Planck Institute for Biophysical Chemistry

Jürgen Helmcke, Physikalisch-Technische Bundesanstalt

Hartmut Hillmer, Institute of Nanostructure Technologies and Analytics (INA), University of Kassel

Günter Huber, Institut für Laser-Physik

Mirco Imlau, Department of Physics, University of Osnabrück

Kuon Inoue, Department of Photonics, Chitose Institute of Science and Technology

Thomas Jüstel, University of Applied Sciences Münster

Jeff L. Kaiser, Spectra Physics, Laser Division

Eckard Krätzig, Physics Department, University of Osnabrück

Ferenc Krausz, Max-Planck-Institut für Quantenoptik

Stefan Kück, Optics Division, Physikalisch-Technische Bundesanstalt

Anne L'Huillier, Department of Physics, University of Lund

Bruno Lengeler, II. Physikalisches Institut, RWTH Aachen

Martin Letz, Materials Science, Central Research, Schott Glas

Gerd Leuchs, Institute of Optics, Information and Photonics, University of Erlangen-Nuremberg

Norbert Lindlein, Institute of Optics, Information and Photonics, University of Erlangen-Nuremberg

Prof. Dennis Lo deceased

Stefano Longhi, Department: Physics, University: Politecnico di Milano

Ralf Malz, LASOS Lasertechnik GmbH

Wolfgang Mannstadt, Schott AG

Dietrich Martin, Microstructured Optics Research, Carl Zeiss AG

Gerd Marowsky, Laser-Laboratorium Göttingen e.V.,

Bernhard Messerschmidt, GRINTECH GmbH

Gerard J. Milburn, Centre for Quantum Computer Technology, School of Physical Sciences, The University of Queensland

Katsumi Midorikawa, Laser Technology Laboratory

Kazuo Ohtaka, Center for Frontier Science, Chiba University

Motoichi Ohtsu, Department of Electronics Engineering, The University of Tokyo

Roger A. Paquin, Advanced Materials Consultant

Alan B. Peterson, Spectra Physics, Laser Division

Klaus Pfeilsticker, Institut für Umweltphysik, Fakultät für Physik und Astronomie, Universität Heidelberg

Ulrich Platt, Institut für Umweltphysik, Fakultät für Physik und Astronomie, Universität Heidelberg

Markus Pollnau, MESA+ Institute for Nanotechnology, University of Twente

Steffen Reichel, Service Division Research and Technology Development, SCHOTT Glas

Hans-Dieter Reidenbach, Institute of Communications Engineering, Institute of Applied Optics and Electronics, University of Applied Sciences Cologne

Hongwen Ren, College of Optics and Photonics, University of Central Florida

Detlev Ristau, Laser Zentrum Hannover e.V.

Simone Ritter, Material Development, SCHOTT AG

Evgeny Saldin, Deutsches Elektronen Synchrotron (DESY)

Roland Sauerbrey, Forschungszentrum Dresden - Rossendorf e.V.

Evgeny Schneidmiller, Deutsches Elektronen Synchrotron (DESY)

Bianca Schreder, Material Development, SCHOTT AG

Christian Schroer, Institute of Structural Physics

Markus W. Sigrist, Department of Physics, Institute of Quantum Electronics

Elisabeth Soergel, Institute of Physics, University of Bonn

Steffen Steinberg, LASOS Lasertechnik GmbH

Sune Svanberg, Division of Atomic Physics, Lund University

Orazio Svelto, University: Politecnico di Milano

Bernd Tabbert, Engineering Department, Semicoa

K. Thyagarajan, Physics Department, Indian Institute of Technology Delhi

Mary G. Turner, Engineering Synthesis Design, Inc

Michael Vollmer, Department of Physics, University of Applied Sciences Brandenburg

Helen Wächter, Department of Physics, Institute of Quantum Electronics

Silke Wolff, Material Development, Optical Glasses, SCHOTT Spezialglas AG

Matthias Wollenhaupt, Institut für Physik, Universität Kassel

Shin-Tson Wu, College of Optics and Photonics, University of Central Florida

Mikhail Yurkov, Deutsches Elektronen Synchrotron (DESY)

Aleksei Zheltikov, Physics Department, M.V. Lomonosov Moscow State University



About the Editor:

Frank Träger is a full professor of experimental physics and head of the Interdisciplinary Center for Nanostructure Science and Technology – CINST at the University of Kassel, Germany.

Frank Träger received the diploma in physics from the University of Heidelberg where he continued his research to earn a Ph.D. in physics in 1974. Following his habilitation, he joined the IBM Almaden Research Center in San José, California, as a guest scientist from 1981 to 1982 and for several sabbaticals until 1986.

Since 1986, he has been an associate Professor at the Institute of Physics of the University of Heidelberg, and since September 1990 a full Professor in the Physics Department of the University of Kassel, Germany. His current

research interests are the preparation and characterization of metal nanoparticles and self-assembled functional films, nonlinear optical phenomena, the study and application of nonthermal desorption and ablation phenomena, ultrafast electron dynamics on the femtosecond timescale, and imaging of DNA by scanning probe microscopies. In his experiments, tunable laser radiation plays an essential role.

Frank Träger serves as the Editor-in-Chief of the international journal Applied Physics B – Lasers and Optics published by Springer. He is a corresponding member of the Heidelberg Academy of Sciences and of acatech, des Konvents für Technikwissenschaften der Union der deutschen Akademien der Wissenschaften e.V.

Table of Contents

Foreword by **Theodor W. Hänsch**

Part A: Basic Principles and Materials

- Chap. 1 Properties of Light
- Chap. 2 Geometrical Optics
- Chap. 3 Wave Optics
- Chap. 4 Nonlinear Optics
- Chap. 5 Optical Materials and Their Properties
- Chap. 6 Thin Films

Part B: Fabrication and Properties of Optical Components

- Chap. 7 Optical Design and Design Software
- Chap. 8 Advanced Optical Components
- Chap. 9 Optical Detectors

Part C: Coherent and Incoherent Light Sources

- Chap. 10 Incoherent Light Sources
- Chap. 11 Lasers and Coherent Light Sources
- Chap. 12 Short and Ultrashort Laser Pulses

Part D: Selected Applications and Special Fields

- Chap. 13 Optical and Spectroscopic Techniques
- Chap. 14 Quantum Optics
- Chap. 15 Integrated Optics
- Chap. 16 Nanooptics
- Chap. 17 Optics Far Beyond the Diffraction Limit
- Chap. 18 Terahertz Photonics
- Chap. 19 X-Ray Optics
- Chap. 20 Atmospheric Optics
- Chap. 21 Holography and Optical Data Storage
- Chap. 22 Laser Safety